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13.

OK TO ENTER: /SR/

RESPONSE UNDER 37 C.F.R. § 1.116 EXPEDITED PROCEDURE REQUESTED 2008 EXAMINING GROUP 1795

03/11/2008

PATENT Attorney Docket No. 04329.3304-00

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Ayako NAKANO et al.

Application No.: 10/823,539

Filed: April 14, 2004

For: PATTERN FORMING METHOD AND SYSTEM, AND METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE Group Art Unit: 1795

Examiner: Stephen D. ROSASCO

Confirmation No.: 4440

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## **REQUEST FOR RECONSIDERATION**

In reply to the final Office Action mailed November 6, 2007, the period for

response to which extends through February 6, 2008, Applicants respectfully request

reconsideration of the above-identified application in light of the following remarks.